

Extreme Ultraviolet Lithography (EUVL) Systems Market by Light Source (Laser Produced Plasmas (LPP), Vacuum Sparks, and Gas Discharges), Tool (Light Source, Mirrors, Mask), and Application (Memory, IDM, Foundry) - Global Opportunity Analysis and Industry Forecast, 2014 - 2022

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Abstracts

Extreme Ultraviolet Lithography (EUVL) is one of the leading next-generation lithography (NGL) technologies used to print lines as small as 30 nm and develop microprocessors & microchips. This technology may replace optical lithography, which is used to device present-day microcircuits. EUVL system works by burning strong beams of ultraviolet light that are reflected from a circuit design pattern into a silicon wafer.

The ability of the EUVL system to offer enhanced resolving power and high productivity & number of transistors, and to produce smaller featured devices drive the growth of the global extreme EUVL systems market. However, EUVL is a complex technology that requires all new step-and-scan systems for production of semiconductors, which acts as a restraint for the market. Reduction in size of transistors and electronic circuits within microprocessors increases the density and power of these systems, which is expected to provide lucrative opportunity for the market growth.

The global EUVL systems market is segmented based on light source, tool, end user, and geography. The light source segment is divided into laser produced plasmas (LPP), vacuum sparks, and gas discharges. On the basis of equipment, the market is categorized into light source, mirrors, masks, scanners and others. By application, it is classified into memory, IDM, foundry, and others. Geographically, it is analyzed across North America (U.S., Mexico, and Canada), Europe (UK, Germany,

France, And Rest Of Europe), Asia-Pacific (China, India, Japan, And Rest Of Asia-Pacific), And Lamea (Latin America, Middle East, And Africa).

Major Companies Profiled In The Report Include Asml, Canon Inc., Intel Corporation, Nikon Corporation, Nuflare Technology Inc., Samsung Corporation, Suss Microtec Ag, Taiwan Semiconductor Manufacturing Company Limited (Tsmc), Ultratech Inc., And Vistec Semiconductor Systems.

Potential Benefits For Stakeholders

Comprehensive Analysis Of The Current Trends And Future Estimations In The Global Euvl Systems Market Is Provided.

The Report Offers A Competitive Scenario Of The Market With Growth Trends, Structure, Drivers, Scope, Opportunities, And Challenges.

It Includes A Detailed Analysis Of The Key Segments To Provide Insights On Market Dynamics.

Porter's Five Forces Analysis Highlights The Potential Of Buyers And Suppliers As Well As The Competitive Structure Of The Market To Devise Effective Growth Strategies And Facilitate Better Decision-Making.

Extreme Ultraviolet Lithography (EUVL) Systems Market Key Segmentation
By Light Source

Laser Produced Plasmas (Lpp)

Vacuum Sparks

Gas Discharges

By Equipment

Light Source

Mirrors

Mask

Scanners

Others

By Application

Memory

Idm

Foundry

Others

By Geography

North America

U.S.

Mexico

Canada

Europe

Uk

Germany

France

Rest Of Europe

Asia-Pacific

China

Japan

India

Rest Of Asia-Pacific

Lamea

Latin America

Middle East

Africa

Key Players

Asml

Canon Inc.

Intel Corporation

Nikon Corporation

Nuflare Technology Inc.

Samsung Corporation

Suss Microtec Ag

Taiwan Semiconductor Manufacturing Company Limited (Tsmc)

Ultratech Inc.

Vistec Semiconductor Systems

Other Players In The Value Chain Include (Profiles Not Included In The Report):

Globalfoundries

Ev Group

Mapper Lithography

Igi

Adama Innovations

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